

Silicon Dioxide (Fused Quartz) (SiO₂) Sputtering Targets

Material Type	Silicon (IV) Oxide	Theoretical Density (g/cc)	2.648
Symbol	SiO ₂	Z Ratio	**1.00
Color/Appearance	White, Crystalline Solid	Sputter	RF
Melting Point (°C)	1,610	Max Power Density	60
Purity:	99.999%, 99.99%, 99.995%	(Watts/Square Inch)	
		Type of Bond	Indium